

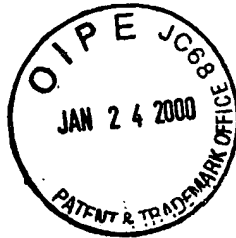
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Koji NOZAKI et al

Serial No.: 09/015,287

Filed: January 29, 1998



Group Art Unit: 1752

Examiner: J. Chu

For: POLYMER COMPOUND FOR A CHEMICAL AMPLIFICATION RESIST AND A FABRICATION PROCESS OF A SEMICONDUCTOR DEVICE USING SUCH A CHEMICAL AMPLIFICATION RESIST

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents  
Washington, D.C. 20231

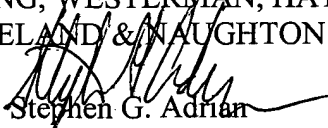
Date: January 24, 2000

Sir:

Applicant petitions the Commissioner of Patents and Trademarks to extend the time for response to the Office Action dated August 24, 1999 for two months from November 24, 1999 to January 24, 2000.

Attached please find a check in the amount of \$380.00 to cover the cost of the extension for a large entity. In the event that any additional fees are due in connection with this paper, please charge our Deposit Account No. 01-2340. Two copies of this paper are enclosed herewith.

Respectfully submitted,  
ARMSTRONG, WESTERMAN, HATTORI,  
McLELAND & NAUGHTON

  
Stephen G. Adrian  
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